Ref. No: EX/PRN/T/226/2017

## B.Printing Engineering Examination 2017

## (Second Year Second Semester)

## Printing Surface Preparation

Time: Three hours Full Marks:100

## Answer any Five questions

- L(a) Why Al is selected as base metal for image surface preparation of Offset Printing?
  - (b) Discuss in brief, the chemical graining and electrochemical graining of Al plate.
  - (c) Discuss in brief the Brush graining methods along with merits and demerits.
  - (d) What is Stop out in deep etch plate making?

5+(3+3)+6+3=20

- 2. (a) What are the purposes of graining Al base plate?
  - (b) What are the purposes of anodizing the grained Al plate?
  - (c) How are the plate grains evaluated?
- (d) What are the preferences of the platemakers and printers so far as plate grains are concerned? Discuss in brief.

  8:4:6:5:20
- 3. (a) What are the factors which influence the mechanical graining of the lithographic plates. Discuss in brief.
  - (b) What are the advantages of the deep etch plates over the surface plates?
- (c) What happens when one step additive development solution is rubbed on exposed diazo plate?

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- 4.(a) What are the factors which affect the thickness of the bichromated colloid coating on grained Al plate used in lithographic surface preparation? Discuss in brief.
- (b) What are the properties Silicone Resin have for which it is used as a material to form the non-image areas of the waterless offset plate?
- (e) What is the constituent of the counter etching solution?
- (d) What is the purpose of the sodium silicate layer in the presensitized offset plate?

- (e) What are the basic constituent of the regular developing solution used in gum deep etch plate making?
- (f) What are the constituent of the etching solution used in gum deep etch plate making? Discuss the functions of them. 7+4+2+2+3=20
- 5. (a) Discuss in brief the basic structure of the negative working waterless offset plate.
- (b) Discuss in brief, the imaging and developing of the negative working waterless offset plate.
- 6. What are the factors which influence the sensitivity to light of the bichromated colloidal films used in lithographic plate making? Discuss in brief.
- 7..(a) Why the pH of the gum arabic solution used in desensitizing of lithographic plate should be kept near about 3.0 for most effective result?
  - (b) What are the purposes of counter etching the lithographic plates?
- (c) What are the properties the gum arabicsolution possess for which it is considered as a desensitizing solution for lithographic plate making?
- (d) Discuss the effect of relative humidity and surface treatment on the coating thickness of bichromated egg-albumen and gum deep etch coatings used in lithography? 5+5+5=20